

AMENDMENTS TO THE SPECIFICATION

Please amend paragraph in page 14 line 14 as follows to correct a clerical errors. Insertions are shown underlined while deletions are ~~struck through~~.

A thickness of the substrate layer may be appropriately selected depending on an application. Generally, a thickness of the conductive resin film with substrate layer and the low resistance layer combined is 5 μm to 0.5 mm, preferably 10 μm to 200 μm . A volume resistance of the conductive resin film as a whole in the thickness direction is 0.01 to 5 Ωcm , preferably 3 Ωcm or less.

Please amend Table 3 in page 28 as follows to correct a clerical errors. Insertions are shown underlined while deletions are ~~struck through~~.

Table 3

		Volume resistance of a conductive film	
Volume rate of a resin	Volume rate of a fine carbon fiber	Example	Referential Example
50%	50%	0.02 Ωcm	A film could not be formed.
60%	40%	0.05 Ωcm	A film could not be formed.
70%	30%	0.08 Ωcm	0.24 Ωcm
80%	20%	0.11 Ωcm	1.20 Ωcm
90%	10%	0.27 Ωcm	50 Ωcm